Compendium of Current Total Ionizing Dose and Displacement Damage Results from NASA Goddard Space Flight Center and Selected NASA Electronic Parts and Packaging Program

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Abstract-- Total ionizing dose and displacement damage testing was performed to characterize and determine the suitability of candidate electronics for NASA space utilization. Devices tested include optoelectronics, digital, analog, linear bipolar devices, and hybrid devices.

Index Terms- Displacement Damage, Optoelectronics, Proton Damage, Single Event Effects, and Total Ionizing Dose.

I. INTRODUCTION

Long term radiation induced failure modes play a significant role in determining space system reliability. Therefore, the effects of total ionizing dose (TID) and displacement damage (DD) need to be evaluated through ground-based testing in order to determine risk to spaceflight applications.

The test results presented here were gathered to establish the sensitivity of candidate spacecraft electronics to TID and/or DD. Proton-induced degradation, dominant for most NASA missions, is a mix of ionizing (TID) and non-ionizing damage. The non-ionizing damage is commonly referred to as displacement damage (DD). For similar results on single event effects (SEE), a companion paper has also been submitted to the 2017 IEEE NSREC Radiation Effects Data Workshop entitled: "Compendium of Current Single Event Effects Results from NASA Goddard Space Flight Center and Selected NASA Electronic Parts and Packaging Program" by M. O'Bryan, et al. [1]

II. TEST TECHNIQUES AND SETUP

A. Test Method

Unless otherwise noted, all tests were performed at room temperature and with nominal power supply voltages. Based on the application, samples were tested in a biased or unbiased configuration. Functionality and parametric changes were measured either continually during irradiation (in-situ) or after step irradiations (for example: every 10 krad(Si), or every 1x10¹⁰ protons/cm²).

B. Test Facilities - TID

TID testing was performed using MIL-STD-883, Test Method 1019.9 [2] unless otherwise noted as research. Dose rates used for testing were between 0.05 and 50 rad(Si)/s.

C. Test Facilities – Proton

Proton damage tests were performed on biased and unbiased devices. Table I lists the proton damage test facilities and energies used on the devices.

TABLE I: PROTON TEST FACILITIES

| Facility | Proton Energy, (MeV) |
|---|-------------------------|
| University of California at Davis (UCD) Crocker Nuclear Laboratory (CNL) | 63 |
| Texas A&M University Cyclotron (TAMU) | 45 |

III. TEST RESULTS OVERVIEW

Abbreviations for principal investigators (PIs) are listed in Table II. Abbreviations and conventions are listed in Table III. Summary of TID and DD test results are listed in Table IV and VI. Summary of on-going TID test results are listed in Table V. Please note that these test results can depend on operational conditions.

TABLE II LIST OF PRINCIPAL INVESTIGATORS

| Abbreviation | Principal Investigator (PI) |
|--------------|-----------------------------|
| DC | Dakai Chen |
| KY | Ka-Yen Yau |
| MCC | Megan C. Casey |
| MJC | Michael J. Campola |

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TABLE III ABBREVIATIONS AND CONVENTIONS

A = Amp

BiCMOS = Bipolar – Complementary Metal Oxide Semiconductor

BJT = Bipolar Junction Transistor

CMOS = Complementary Metal Oxide Semiconductor

CTR = Current Transfer Ratio

DDD = Displacement Damage Dose

DDR = Double-Data-Rate (a type of SDRAM—Synchronous Dynamic

Random Access Memory)

DTRA = Defense Threat Reduction Agency

DUT = Device Under Test

ELDRS = Enhanced Low Dose Rate Sensitivity

FET = Field Effect Transistor

GSFC = Goddard Space Flight Center

HDR = High Dose Rate

H_{FE} = Forward Current Gain

 $I_b = Base Current$

I_c = Collector Current

 I_{CE} = Collector-Emitter Current

 I_{os} = Offset Current

I_{off} = Dark Current

 $I_{OUT} = Output \ Current$

JFET = Junction Field Effect Transistor

LBNL = Lawrence Berkeley National Laboratory

LDC = Lot Date Code

LDO = Low Dropout

LED = Light Emitting Diode

LDR = Low Dose Rate

 $LDR\ EF = Low\ Dose\ Rate\ Enhancement\ Factor$

MeV = Mega Electron Volt

mA = milliamp

MOSFET = Metal Oxide Semiconductor Field Effect Transistor

Mrad = mega rad

N/A = Not Available

Op-Amp = Operational Amplifier PI = Principal Investigator

PMU = Pulse Measurement Unit

REAG = Radiation Effects & Analysis Group

RF = Radio Frequency

SEE = Single Event Effects

SMD = Standard Microcircuit Drawings

Spec = Specification(s)

TAMU = Texas A&M University Cyclotron TAMU)

TID = Total Ionizing Dose

UCD-CNL = University of California at Davis – Crocker Nuclear Laboratory

TABLE IV SUMMARY OF TID TEST RESULTS

| Part Number | Manufacturer | LDC | Device Function | Technology | PI | Results | App. Spec (Y/N) | Dose rate (mrad(Si)) | Degradation Level (krad (Si)) | | |
|----------------------------|-------------------|-------------------------------|-------------------------------------|-----------------|-----|--|-----------------------|---------------------------|-------------------------------------|--|--|
| OPERATIONAL AMPLIFIERS | | | | | | | | | | | |
| AD654 | Analog Devices | n/a; (16-036) | Operational Amplifier | Bipolar | МЈС | All parameters within specification up to 40 krad(Si) | Y | 10 | >40 | | |
| PA02 | APEX | 1417; (16-033) | Operational Amplifier | Bipolar | DC | All parameters within specification up to 30 krad(Si) | Y | 10 | >30 | | |
| LTC6268-10 | Linear Technology | 1433; (16-040) | Operational Amplifier | BiCMOS | DC | Minimal degradation up to 20 krad(Si) | Y | 10 | >20 | | |
| TRANSISTORS | | | | | | | | | | | |
| 2N2907AUB | Microsemi | n/a; (16-022) | PNP Transistor | Bipolar | KY | Gain degradation and failures at 45krad (Si) | Y | 10 | 45 | | |
| JANTXV2N2222AUB | Microsemi | 1523: (16-021) | NPN Transistor | Bipolar | KY | Gain out of specification at 55 krad(Si) | Y | 10 | 45 < X < 55 | | |
| JANTXV2N5115 | Solitron | 1449A; (16-039) | JFET | Bipolar | MJC | Minimal degradation up to 30 krad(Si) | Y | 10 | >30 | | |
| MEMORY | | | | | | | | | | | |
| MT29F128G08AJAAAWP- ITZ | Micron | 201504; (16-017) | Flash | CMOS | МЈС | Large number of block errors at 30 krad(Si), Three devices showed unrecoverable chip select errors at 40 krad(Si) | N | 0.7 – 10 rad(Si)/s | 30 | | |
| MT29F128G08AJAAAWP- ITZ | Micron | 201504BYGGFZR.21; (16-018) | Flash | CMOS | МЈС | Two devices showed unrecoverable chip select errors | N | 0.7 – 10 rad(Si)/s | 40 | | |
| MB85AS4MT | Fujitsu | 1638; (16-041) | Memory – Nonvolatile | CMOS & ReRAM | DC | No memory corruption observed. Peripheral circuitry failure observed > 20 krad (Si). | N | 50 rad(Si)/s | 20 < X < 50 | | |
| MISCELLANEOUS | | | | | | | | | | | |
| AD2S80 | Analog Devices | 1452; (15-088) | Resolver to Digital Converter | BiCMOS | DC | Biased parts show functional failure between 18 and 30 krad(Si) at high dose rate and 12 to 18 krad(Si) at low dose rate. | Y | 50 rad(Si)/s and 10 | 12 <ff<18< td=""></ff<18<> | | |

| Part Number | Manufacturer | LDC | Device Function | Technology | PI | Results | App. Spec (Y/N) | Dose rate (mrad(Si)) | Degradation Level (krad (Si)) |
|-------------|---------------------------------|----------------------|---------------------------------------|------------|-----|---|-----------------------|-------------------------|-------------------------------------|
| UC1823A | Texas Instruments | 1345; (15-062) | Pulse Width Modulator Modulator | BiCMOS | DC | All parameters within specification up to 30 krad(Si) | Y | 10 | > 30 |
| SW15-802 | Southwest Research Institute | 1203, 1233; (16-007) | Optocoupler | Hybrid | МСС | One unbiased part showed an increase in dark current at 75 krad(Si). Parameters increased with dose for biased parts. | Y | 5 – 50 rad(Si)/s | 8 < X < 75 |
| AD9364 | Texas Instruments | n/a; (15-071) | Transceiver | CMOS | DC | Parameters within specification. Transmission power gain showed minimal degradation as dose increased | Y | 100 rad(Si)/s | > 50 |

TABLE VI SUMMARY OF ON-GOING TID TEST RESULTS

| Part Number | Manufacturer | LDC | Device Function | Technology /Package | PI | Results | App. Spec (Y/N) | Dose rate (mrad(Si)) | Degradation Level (krad (Si)) |
|--------------------|--|----------------|--------------------------|--|----|--|-----------------------|-------------------------|-------------------------------------|
| OPERATIONAL AMPLIF | TIERS | | | | | | | | |
| RH1013MH | Linear Technology | 0329A; (A214) | Operational Amplifier | Bipolar / TO-5 Metal Can | DC | Small levels of dose rate sensitivity in the I _B degradation. Parameters within spec. | Y | 0.5 | >20 $40 < I_B \le 60$ |
| RH1013MJ8 | Linear Technology | 0305A; (A214) | Operational Amplifier | Bipolar /Ceramic DIP | DC | Small levels of dose rate sensitivity in the I _B degradation. Parameters within spec. | Y | 1 | >20 |
| | | | | | | - | | 0.5 | $40 < I_B \le 60$ |
| RH1078MH | Linear Technology | 0741A; (A224) | Operational Amplifier | Bipolar /TO- | DC | Parameters remain within post-irradiation specification. Completed 11/22/2016. | Y | 0.5 | >40 |
| | | | | | | Parameters remain | | 1 | >40 |
| RH1078W | Linear Technology 0325A; (A224) Operational Amplifier Flatpack | | DC | within post-irradiation specification. Completed 11/22/2016. | Y | 0.5 | >30 | | |
| RHF43B | STMicroelectronics | 30820A; (A589) | Operational | BipolarBipo | DC | Minimal dose rate | N | 10 | >100 |

| Part Number | Manufacturer | LDC | Device Function | Technology /Package | PI | Results | App. Spec (Y/N) | Dose rate (mrad(Si)) | Degradation Level (krad (Si)) |
|--------------------|--------------|-----------------------------|--------------------|------------------------|----|--|-----------------------|-------------------------|-------------------------------------|
| | | | Amplifier | lar / Ceramic | | sensitivity. Parameters | | 1 | >50 |
| | | | | Flat-8 | | within spec. Completed 12/16/16 | | 0.5 | >50 |
| TRANSISTORS | | | | | | | | | |
| | | | NPN | Bipolar / | | Minimal degradation. | | 10 | >100 |
| 2N2222 | Semicoa | 1001; (1324) | Transistor | Engineering | DC | All parameters within | N | 1 | >40 |
| | | | | -Samples | | spec. [43] | | 0.5 | >20 |
| | | | | | | LDD FE 20 AG | N | 10 | 35 < h _{FE} < 45 |
| 2N2222AJSR | Semicoa | 1001 ; (13-024) | NPN Transistor | Bipolar | DC | LDR EF = 3.9 After 100 krad(Si). | 11 | 5 | 65 < h _{FE} < 90 |
| | | | Tansistor | | | Completed in 2016. | | 1 | >40 |
| | | | | | | | | 0.5 | >30 |
| | | | | | | No bias dependence. | | 1 | $30 < h_{FE} < 50$ |
| 2N3811JS | Semicoa | 1230; (13-063) | PNP Transistor | Bipolar | DC | Two devices exceeded specifications after 30 krad(Si). Completed 12/3/2016. | N | 0.5 | $60 < h_{FE} \le 70$ |
| 2N2907 | Semicoa | 0932; (13-023) | PNP Transistor | Bipolar | DC | LDR EF = 1.78 after 100 krad(Si). Completed 12/3/2016. | N | 10 | $40 < h_{FE} < 50$ |
| 2N2369 | Semicoa | J1934(wafer#); (13- 020) | NPN Transistor | Bipolar | DC | All parameters within specification up to 100 krad(Si). Minimal LDR sensitivity. Completed Nov. 2016 | N | 1 | > 100 |
| | | | | | | Strong bias dependence. Biased | | 1 | $30 < H_{FE} < 40$ |
| 2N3700JV | Semicoa | 1109; (13-022) | NPN Transistor | Bipolar | DC | devices show enhanced degradation than grounded devices. Completed 6/23/2016. | N | 0.5 | >20 |
| 2) (2700) (D.1) | g . | J1935(wafer#); (13- | NPN | D: 1 | DC | Dose rate effect not | N | 1 | $10 < H_{FE} < 20$ |
| 2N3700UBJV | Semicoa | 021) | Transistor | Bipolar | DC | evident at this stage. Completed 6/23/2016. | N | 0.5 | $15 < H_{FE} < 30$ |
| TRANSISTORS, CONT. | | | | | | | | | |
| 2N5153 | Semicoa | 1013 ; (13-018) | PNP | Bipolar | DC | Minimal LDR EF. | N | 1 | >50 |

| Part Number | Manufacturer | LDC | Device Function | Technology /Package | PI | Results | App. Spec (Y/N) | Dose rate (mrad(Si)) | Degradation Level (krad (Si)) |
|-------------------|---------------------------|-----------------------|---|------------------------------|----|--|-----------------------|-------------------------|-------------------------------------|
| | | | Transistor | | | Completed 11/22/2016. | | | |
| 2N5154 | Semicoa | 1023; (13-019) | NPN Transistor | Bipolar | DC | Minimal LDR EF. Completed 11/22/2016. | N | 1 | >50 |
| VOLTAGE REFERENCE | S/REGULATORS | | | | | | | | |
| LM136AH2.5QMLV | National Semiconductor | 200746K019; (A164) | Voltage Reference | Bipolar/3- LEAD TO- 46 | DC | Exhibits no LDR enhancement. | N | 0.5 | >70 |
| LM317LTTR | Texas Instruments | 0608; (A113) | Positive Voltage Regulator | Bipolar | DC | Parameters within specification. Observed LDR sensitivity for parts irradiated at 0.5 after 20 krad(Si). | N | 0.5 | > 70 |
| LT1009IDR | Texas Instruments | 0606; (A327) | Internal Reference | Bipolar | DC | Parameters within specification. Parts exhibit minimal LDR enhancement. | N | 0.5 | > 70 |
| RHFL4913ESY332 | STMicroelectronics | 30828A; (A259) | Voltage Regulator | Bipolar/TO- 257 | DC | All parameters within specification. Minimal dose rate sensitivity. Completed 7/22/2016. | N | 0.5 | > 60 |
| RHFL4913KP332 | STMicroelectronics | 30814B; (A258) | Voltage Regulator | Bipolar/Flat- 16 | DC | All parameters within specification. Minimal dose rate sensitivity. Completed 7/22/2016. | N | 0.5 | > 60 |
| TL750M05CKTRR | Texas Instruments | 0707; (A112) | LDO Positive Voltage Regulator | Bipolar/TO- 263-3 | DC | Minimal dose rate sensitivity. | N | 0.5 | > 70 |
| MISCELLANEOUS | | | | | | | | | |
| LM139AWRQMLV | National Semiconductor | JM046X13; (A211) | Comparator | Bipolar | DC | Parameters within specification. Completed 11/22/2016. | Y | 0.5 | $I_b > 75$ |

TABLE V SUMMARY OF DD TEST RESULTS

| Part Number | Manufacturer | LDC | Device Function | Technology | PI | Results | App. Spec (Y/N) | Proton Fluence (/cm²) |
|-------------|---------------------------------|-------------------------|--------------------|------------|-----|--|-----------------------|--|
| SW15-802 | Southwest Research Institute | 1203, 1233; (16-007) | Optocoupler | Hybrid | MCC | Increase of dark current and decrease of CTR with increasing fluence | Y | $6x10^{10} < I_{\text{off}} < 3X10^{11}$ |
| HSSR-7111 | Micropac | 1614; (16- 035) | Optocoupler | Hybrid | МЈС | Some degradation in turn on time, leakage prevents turn off | Y | $3x10^{11} < I_{off} < 4X10^{11}$ |
| OPB848 | Optek | n/a; (17- 009) | Optocoupler | Hybrid | МЈС | On-state collector current out of specification at 1.12x1011cm-2 | Y | 1.12x10 ¹¹ cm ⁻² |

IV. TEST RESULTS AND DISCUSSION

As in our past workshop compendia of GSFC test results, each device under test has a detailed test report available online at http://radhome.gsfc.nasa.gov [3] and at http://nepp.nasa.gov [4] describing in further detail the test method, conditions and monitored parameters, and test results. This section contains a summary of testing performed on a selection of featured parts.

A. AD9364, Analog Devices, RF Transceiver

The AD9364 is a commercial-off-the-shelf high performance, highly integrated radio frequency (RF) Agile Transceiver designed for use in 3G and 4G base station applications. It is built on a commercial 65 nm CMOS process. TID testing was carried out on four samples at an average dose rate of 100 rad(Si)/sec.

The device under test (DUT) was configured as a part of the AD-FMCOMMS4-EBZ evaluation platform. The AD-FMCOMMS4-EBZ evaluation platform interfaced with the ZedBoard. The ZedBoard contains the Zynq-7020 Systemon-Chip (SoC), 512 MB DDR3, 256 Mb Quad-SPI flash, and 4 GB SD memory card. Fig. 1 shows a photograph of the test setup on the bench, with the evaluation cards mated with the ZedBoard. Fig. 2 shows the top and bottom view of the evaluation board. The AD9364 is circled. As shown, there are several other active components mounted on the bottom of the board. During irradiation, the entire ZedBoard was positioned behind lead brick shielding. We performed dosimetry at various locations behind the shielding, and determined that at a spot one inch away from the edge of the shielding, the total dose is negligible. However, approximately ½ inch away from the edge, the total dose will be a fifth of the total dose received by the DUT at the unshielded target. Therefore, the components on the evaluation card near the edge of the shielding accumulated approximately 5 - 10 krad(Si) during the exposure.



Fig. 1. Photograph of the test setup.

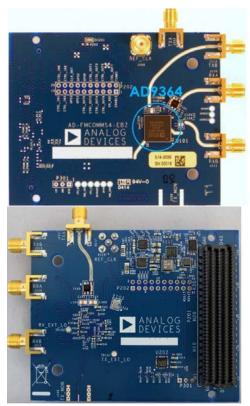
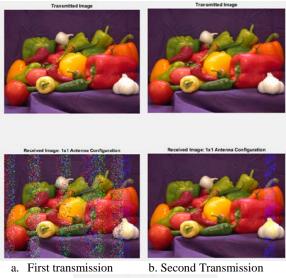


Fig. 2. Top and bottom view of the AD-FMCOMMS4-EBZ evaluation board.

The parts exhibited limited degradation in general. Most of the electrical parameters showed negligible change up to 50 krad(Si). The transmission power gain showed some degradation with increasing total dose. The gain degradation manifested visually through the image transmission tests. Fig. 3 shows a pristine image and an image transmitted with a gain of 62 dB after 50 krad(Si). We show the results from two transmission operations. The second test, shown in Fig. 3b, produced relatively fewer errors. In both cases, the transmitted image post-irradiation becomes pixelated due to the loss in power. Fig. 3, third image, shows the pre-irradiation and post-irradiation image with a gain of 50 dB. The pixilation is reduced significantly. The pixilation issue disappears at higher transmission power.





c. Third Transmission

Fig. 3. Pre-irradiation (top) and post-irradiation (bottom) images transmitted after 50 krad(Si) for DUT2. The first and second images represent the first (a) and second (b) transmission, respectively. The second transmission produced relatively fewer errors. The third image transmitted (c) with gain of 50 dB after 50 krad(Si) for DUT2.

B. HSSR-7111, Micropac, Optocoupler

The HSSR-7111 is a single-channel power MOSFET optocoupler rated for 90 V. It is available to Standard Microcircuit Drawings (SMD) specifications as 5962-9314001HPA. Displacement Damage testing was conducted on ten samples at CNL-UCD. To avoid part overstress a Keithley Pulse Measurement Unit (PMU) was used for pulse sweeping the device parameters, this also reduces internal heating of the device. During testing we saw two types of degradation on the optocoupler, increased turn on time delay and leakage on the output MOSFET.

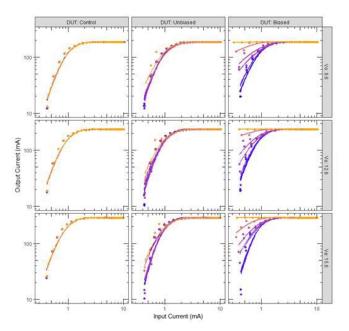


Fig. 4a. Output current for a given input current using pulsed measurements.

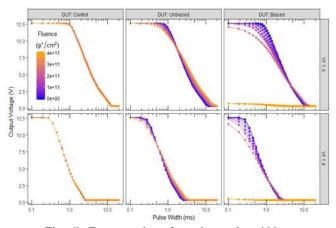


Fig. 4b. Turn-on voltage for a given pulse width.

The degradation shown in Fig. 4a details the biased parts as being more susceptible to proton exposure. At the final tested fluence step, the devices were permanently "on" independent of input current. This effect is attributed to the leakage path through the Metal Oxide Semiconductor Field Effect Transistor (MOSFET) stage of the device. This degradation remained present even as no bias was on the LED stage. Fig. 4b however shows the delay in turn on time for given pulse widths synchronized on the drain of the MOSFET and high side of the LED. The delay is more pronounced for the unbiased devices, and therefore is suspected to be degradation of the LED and/or material that the light propagates through.

C. SW15-802, Southwest Research Institute, High Voltage Optocoupler

The SW15-802 is a ±6 kV optocoupler with 5 LED junctions. It employs low outgassing space-grade potting and coating. The internal high-voltage diode is glasspassivated and rated at 15 kV. Fig. 5 shows a pin configuration for this uniquely packaged device.

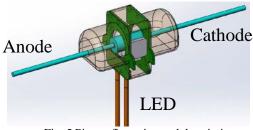


Fig. 5 Pin configuration and description.

TID testing was carried out on eight parts to a total dose of 150 krad(Si). The four unbiased parts, with all pins grounded, were irradiated first at a dose rate of 50 rad/s. Only small degradation was observed up to 75 krad. After this dose step, the dark current parameter for one part increased ten times from the pre-irradiation value. These results are shown in Fig. 6. Only small increases in the CTR measurement were observed for LED current conditions of 10 mA and 20 mA. A large CTR increase was seen with an LED current of 0 mA, almost ten times the pre-radiation value.

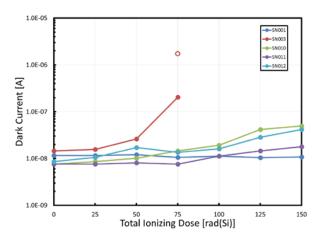


Fig. 6 Dark current versus TID for the parts irradiated unbiased.

The remaining four parts were biased at ±6.1 kV on the anode and cathode and no LED bias current. All four parts were irradiated together up to 7.6 krad. At this point, the parts were drawing too much current for the 10 kV Stanford Research Systems power supply. One part was then irradiated at a time and the dose rate was reduced from 50 rad/s to about 5 rad/s. SN056 showed almost a thirty times increase in the dark current parameter at 7.6 krad. The open circle shown for SN056 are measurements of the part that were taken four days later after a 60C

annealing. There was some recovery, but the dark current still shows about a twenty times increase compared to the pre-rad value. This confirmed that the parts did experience some recovery from annealing, but most of the damage remained. The other three irradiated parts each had about 10x increase in dark current. Fig. 7 shows the biased parts results for the dark current parameter. Similar results were seen in the biased parts for CTR as in the unbiased parts. At an LED current of 0 mA the CTR increased by thirty-eight times, while the LED current conditions of 10 mA and 20 mA only saw about a 5% increase.

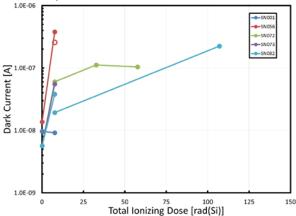


Fig. 7 Dark current versus TID for the parts irradiated while biased at ± 6.1 kV.

Displacement damage testing was also conducted on eight parts at TAMU. Four parts were irradiated with diode and LED grounded and the remaining four parts were irradiated with the diode grounded but the LED biased at 20 mA. There were two control devices. The parts were irradiated in $6x10^{10}$ p/cm² steps up to a total fluence of $3x10^{11}$ p/cm².

In both the biased and unbiased parts, dark current increased as the proton fluence increased. Fig. 8 and 9 show these test results. Similar results were also seen in the CTR parameter. CTR decreased as fluence increased when the LED current conditions were 10 mA and 20 mA but increased when the LED current was 0 mA.

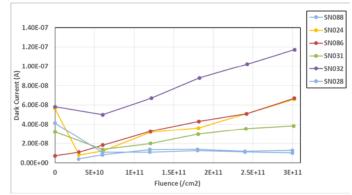


Fig. 8 Dark current as a function of proton fluence for the unbiased parts.

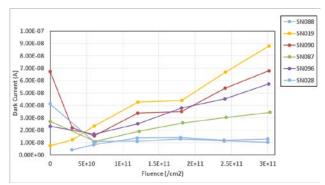


Fig. 9 Dark current as a function of proton fluence for the biased parts.

V. SUMMARY

We have presented data from recent TID tests on a variety of primarily commercial devices. It is the authors' recommendation that this data be used with caution due to many application/lot-specific issues. We also highly recommend that lot testing be performed on any suspect or commercial device. As in our past workshop compendia of GSFC test results, each DUT has a detailed test report available online describing in further detail, test method, TID conditions/parameters, test results, and graphs of data [3].

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